

ABSTRACT OF THE DISCLOSURE

Disclosed herein is a nail varnish composition comprising, in a cosmetically acceptable medium, at least one film-forming polymer, wherein the varnish composition is capable of forming a film having a rate of mass loss of less than 0.5 mg/minute when the film is subjected to abrasion produced with the Taber abrasimeter at 23°C, as well as a method for making up and/or non-therapeutic care of the nails comprising applying to the nails the composition.